

MAGNETORESISTIVE SENSOR ELEMENT AND METHOD FOR REDUCING THE ANGLE ERROR OF A MAGNETORESISTIVE SENSOR ELEMENT

The present invention relates to a magnetoresistive sensor element and a method for reducing the angle error of a magnetoresistive sensor element according to the species defined in the independent claims.

5 Background Information

Because of their enlarged measuring range of 360° and enlarged signal amplitudes and thus lower susceptibility to interference compared to AMR angle sensors, magnetoresistive sensor elements based on the GMR (giant magneto resistance)

10 effect according to the so-called spin valve principle are increasingly being utilized for angle detection in motor vehicles. To that end, the sensor system has a field-generating magnet and an angle sensor, or more generally a magnetoresistive sensor element, positioned in proximity
15 thereto, the direction of the magnetic field acting on this sensor element being detected.

The design of magnetoresistive sensor elements on the basis of the spin valve principle differs from GMR sensor elements or GMR multilayers, which have an alternating sequence of
20 ferromagnetic and non-magnetic thin layers, to the effect that as a rule, only two ferromagnetic thin layers are provided that are separated by a non-magnetic intermediate layer. The

direction of the magnetization of one of these two ferromagnetic layers is then fixed (pinned) by a coupling of this layer to an anti-ferromagnetic layer. The other layer, the so-called free layer or detection layer, on the other 5 hand, in an outer magnetic field is able to freely rotate the direction of its magnetization, so that an angle, variable via the direction of the outer magnetic field, sets in between the direction of the magnetization in the detection layer and the direction of the magnetization in 10 the pinned layer, i.e., the so-called reference layer. The electrical resistance of the sensor element is moreover a function of this angle, so that this angle can be determined 15 by measuring the electrical resistance.

Alternatively, a layer system having an anti-ferromagnetic 15 layer, a ferromagnetic layer situated thereon, a non-magnetic layer on it, and a ferromagnetic layer thereon is also suitable for fixing the direction of the magnetization of the reference layer, the non-magnetic layer between the two 20 ferromagnetic layers imparting an anti-ferromagnetic coupling between them. Such a layer system is known as an artificial anti-ferromagnet.

To permit implementation of an angle sensor having magnetoresistive layer systems operating on the basis of the GMR effect and constructed according to the spin valve 25 principle, it is beneficial to interconnect a plurality of such magnetoresistive layer systems in two Wheatstone bridge circuits, one bridge being rotated by 90°, for example, compared to the other with respect to the direction of the magnetization in the reference layer. In an outer rotating 30 magnetic field, for instance, this leads to a phase shift in the output signals of both bridges. One speaks here of a "cosine" bridge and a "sine" bridge according to the

dependence of the output signal of the two bridges on the outer magnetic-field direction. Each of the individual Wheatstone bridges is further made up of magnetoresistive layer systems in the form of four single resistors, which 5 pairwise have a direction of magnetization in the reference layer of, for example, 180° relative to each other.

WO 00/79298 A2 gives an overview of the design of magnetoresistive layer systems that are constructed according to the spin valve principle and operate according to the GMR 10 effect. Also clarified there is the interconnection of such magnetoresistive layer systems in the form of two Wheatstone bridge circuits rotated by 90° relative to each other, as well as the structure of a magnetoresistive layer system having an 15 artificial anti-ferromagnet for setting a fixed direction of the magnetization of the reference layer of the layer system.

Measuring errors due to two intrinsic effects occur when working with magnetoresistive layer systems that operate on the basis of the GMR effect and are constructed according to the spin valve principle.

20 Thus, the detection layer or free layer has a certain anisotropy on one hand, and on the other hand, a residual coupling with the reference layer or pinned layer, i.e., it does not optimally follow the outer magnetic field with respect to its direction. Moreover, one also observes that the 25 direction of the magnetization of the reference layer does not remain completely unchanged when an outer magnetic field acts on it. In this respect, a slight change in the direction of the magnetization of the reference layer also frequently occurs in response to the influence of an outer magnetic 30 field, which invalidates the measuring result.

The object of the present invention is to provide a magnetoresistive sensor element having a reduced angle error

compared to the related art, and a method for reducing the angle error of a magnetoresistive sensor element, to thus permit use of this magnetoresistive sensor element as a particularly precise angle sensor, especially in motor vehicles.

Summary of the Invention

Compared to the related art, the magnetoresistive sensor element of the present invention and the method of the present invention for reducing the angle error of a magnetoresistive sensor element have the advantage that the angle error of the layer system as a function of the angle between the magnetization direction of the reference layer in the absence of an outer magnetic field and the longitudinal direction of the striated layer system, as well as the field strength of the magnetic field acting from outside is at least approximately minimal. In particular, it is possible to achieve angle errors of less than 0.5° , especially less than 0.2° .

Advantageous refinements of the present invention are yielded from the measures cited in the subclaims.

Thus, it is particularly advantageous if, in addition to the suitable selection of the angle between the magnetization direction in the reference layer in the absence of the outer field and the longitudinal direction of the striated layer system, as well as the suitable selection of the field strength of the outer magnetic field, to further minimize the angle error, one also changes the width of the striated layer system, and thus in each case matches the indicated angle and the width of the striated layer system to the magnetic field, acting upon the sensor element during operation of the latter, whose strength is selected from a predefined work interval.

The angle error is therefore minimized as a function of these variables.

This procedure is based on the knowledge that, by skillful utilization of microscopic energy terms, it is possible to 5 minimize the intrinsic effects that occur when using magnetoresistive sensor elements according to the spin valve principle and that lead to measuring errors.

Thus, one such important effect or energy contribution is the shape anisotropy which occurs when structuring the 10 magnetoresistive layer system in strips. Therefore, the angle error of the magnetoresistive layer system may be minimized by skillful utilization of the shape anisotropy, for example, of a meander-shaped printed circuit trace, which is made up of individual strip-shaped sections, in combination with a 15 suitable selection of the pinning direction of the reference layer of the layer system in this striated region, as well as taking into account the outer magnetic-field strengths acting on the sensor element during its operation.

Therefore, an especially small angle error results, given a 20 suitable combination of the layout of the magnetoresistive layer system in plan view, above all with respect to the width of the individual strip-shaped layer-system sections, and the direction of the magnetization of the reference layer, i.e., the so-called pinning direction, in these individual strip-shaped sections, as well as in simultaneous view of the amount 25 of the outer magnetic field acting on the magnetoresistive sensor element during operation.

It is particularly advantageous that, by structuring the magnetoresistive layer system in strip-shaped sections having 30 a preferred width in the range of 1 μm to 20 μm , the energy contribution of the shape anisotropy, given certain angles between the longitudinal direction of the strip and the

pinning direction, i.e., the direction of the magnetization of the reference layer in the absence of an outer magnetic field or in the case of a negligibly weak outer magnetic field, has a positive influence on the angle error.

5 Thus, it has proven to be particularly advantageous if this angle between the magnetization direction in the absence of the outer magnetic field and the longitudinal direction of the striated layer system is at least approximately 0°, 90°, 180° or 270°, the field strength of the outer magnetic field

10 further advantageously being selected from a work interval of 0.8 kA/m to 80 kA/m, particularly 8 kA/m to 30 kA/m.

In this connection, it is further advantageous if the layout of the magnetoresistive sensor element is selected in such a way that to the greatest extent possible, all strip-shaped

15 sections of the layer system in plan view have only one common direction between the longitudinal direction of the striated layer system in this area and the pinning direction.

In addition, it is advantageous if the sections of the magnetoresistive sensor element not meeting this condition are

20 bridged or electrically short-circuited by a conducting layer exhibiting good electroconductivity, particularly a coating of aluminum, or if these sections of the magnetoresistive sensor element are implemented from corresponding sections exhibiting good electroconductivity.

25 It is also advantageous if the striated layer system in plan view is in the form of a meander having strip sections running regionally in parallel, the magnetization directions of the reference layer of the parallel strip sections being oriented at least approximately parallel to one another, and strip

30 sections running not parallel, but rather in particular running perpendicularly to these strip sections being provided with this conducting layer.

Moreover, it is especially advantageous if the striated, magnetoresistive layer system has an artificial anti-ferromagnet to stabilize the direction of the magnetization of the reference layer. This results in a particularly good and 5 stable stipulation of the magnetization direction of the reference layer.

Brief Description of the Drawing

The present invention is explained in detail in light of the drawing, and in the following description. Figure 1 shows 10 several simulation curves for the angle error of a layer system according to the spin valve principle, operating on the basis of the GMR effect, as a function of the strip width and as a function of the angle between the longitudinal direction of this strip and the direction of the magnetization of the 15 reference layer in the case of a first magnetic field; Figure 2 shows a simulation analogous to Figure 1 for a second magnetic field which is stronger compared to Figure 1; Figure 3 shows a plan view of a meander-type layer system having short-circuit bars provided regionally; and Figure 4 shows a 20 section through a magnetoresistive layer system according to Figure 3.

Exemplary Embodiments

Figure 4 shows a magnetoresistive layer system 10 which, in plan view, at least regionally, particularly completely, has a 25 strip-type structure. To that end, provided on a customary substrate 30 is a growth layer or a buffer layer 31, on which an anti-ferromagnetic layer 32 is situated. Disposed on this layer 32 is a layer system in the form of an artificial anti-ferromagnet 40 having a first fixed layer 35, i.e., a "pinned" 30 layer or a reference layer, an intermediate layer 34 and a second fixed layer 33. Situated on artificial anti-ferromagnet 40 is furthermore a metallic layer 36, and on it a detection

layer 41 made up of a first sublayer 37 and a second sublayer 38. Finally, a customary cover layer 39 made, e.g., of tantalum is located on detection layer 41.

First fixed layer 35 is made of a first ferromagnetic material, preferably a CoFe alloy such as Co₉₀Fe₁₀. Second fixed layer 33 is made of a second ferromagnetic material, preferably likewise a CoFe alloy such as Co₉₀Fe₁₀. Intermediate layer 34 is made of a non-magnetic material, preferably ruthenium. The thickness of first fixed layer 35 is less, particularly by 0.2 nm to 0.8 nm, preferably by 0.2 nm to 0.4 nm, than the thickness of second fixed layer 33. Anti-ferromagnetic layer 32 is preferably made of a PtMn alloy such as Pt₅₀Mn₅₀. Metallic layer 36 is preferably a copper layer. First sublayer 37 of detection layer 41 adjacent to metallic layer 36 is preferably made of a CoFe alloy such as Co₉₀Fe₁₀, and second sublayer 38 is preferably made of a NiFe alloy like Fe₁₉Ni₈₁.

Particularly preferably, anti-ferromagnetic layer 32 has a thickness of 20 nm to 40 nm, especially 30 nm; second fixed layer 33 has a thickness of 2 nm to 4 nm, especially 2.4 nm; intermediate layer 34 has a thickness of 0.6 nm to 0.8 nm, especially 0.7 nm; first fixed layer 35 has a thickness of 1 nm to 3.5 nm, especially 2 nm; metallic layer 36 has a thickness of 1 nm to 4 nm, especially 2 nm; first sublayer 37 has a thickness of 0.5 nm to 2 nm, especially 1 nm; and second sublayer 38 has a thickness of 1.5 nm to 5 nm, especially 3 nm.

Achieved all in all by the layer structure according to Figure 4 is that reference layer 35 has a direction of magnetization at least approximately uninfluenced by a direction of an outer magnetic field acting on it, provided the magnetic field is selected from a predefined work interval. Moreover, detection

layer 41 has a direction of magnetization which is at least approximately constantly parallel to the direction of a component of the field strength of an outer magnetic field, the component lying in the plane of layer system 10.

5 Figure 3 shows a top view of Figure 4, it being discernible that striated layer system 10 is constructed in particular in the form of a meander having strip sections running regionally in parallel. Moreover, in this context, the magnetization directions of reference layers 35 of these individual
10 parallel-running strip sections are likewise oriented at least approximately parallel to each other. In addition, striated layer system 10 has strip parts that regionally run perpendicular to the parallel-running strip sections, and are covered by a conducting layer 11. This conducting layer 11 is
15 a layer having particularly good electrical conductivity, especially a coating of aluminum, which runs parallel to the strip parts in question and therefore electrically short-circuits or bridges them. Alternatively, these strip parts may also be made of the material of conducting layer 11, so that
20 they regionally connect the strip sections running side-by-side, analogous to Figure 3.

Figure 3, by way of the drawn-in arrow, indicates the uniform direction of the magnetization of reference layers 35 in individual striated layer systems 10 running parallel to one
25 another. The structure according to Figure 3 forms a magnetoresistive sensor element 5 which, according to the teaching in WO 00/79298 A2, may be interconnected in the form of Wheatstone bridge circuits and built up to form an angle sensor.
30 The angle error of magnetoresistive layer systems on the basis of the GMR effect according to the spin valve principle - this angle error being defined as the difference of the angle

between the "outer-magnetic-field component lying in the plane of the layer system and the magnetization direction of the reference layer of the layer system given a negligibly weak outer magnetic field, and the measurement angle, ascertained

5 from the measuring signal, between the outer-magnetic-field component lying in the plane of the layer system and the magnetization direction of the reference layer - is dominated by microscopic energy terms of the individual layers of layer system 10.

10 In the ideal case, the angle error should be 0° , i.e., the direction of the magnetization of reference layer 35 should be completely uninfluenced by an outer magnetic field, and the direction of the magnetization of detection layer 41 should always completely follow this outer magnetic field and be
15 aligned in parallel with respect to it.

In practice, however, as a result of the anisotropy of detection layer 41, as well as a ferromagnetic or anti-ferromagnetic residual coupling between detection layer 41 and reference layer 35, detection layer 41 does not follow the
20 outer magnetic field in completely free fashion.

Above all, the shape anisotropy is an essential parameter in order to reduce the angle error, since the strength of this anisotropy can be adjusted by the selection of the width of the individual strips in layer system 10, and the directional
25 dependency of this shape anisotropy can be adjusted by the angle between the longitudinal direction of this strip and the direction of magnetization of the reference layer.

Thus, given a predefined magnetic field, by changing the strip width and the angle between the longitudinal direction of the
30 strip and the direction of magnetization of the reference layer, these energy terms may be optimally adapted to the specific layer system 10.

The indicated energy terms can be formally integrated into the Stoner-Wohlfahrth model of magnetism and calculated, given a predefined outer magnetic field which has been selected from a customary work interval for magnetoresistive sensor elements 5 of 0.8 kA/m (corresponding to 1 mT) to 80 kA/m (corresponding to 100 mT), in particular from a range of 8 kA/m to 30 kA/m.

For layer system 10 according to Figure 4 in the structure according to Figure 3, calculations were carried out with inclusion of the shape anisotropy and the AMR error, 10 respectively, which are represented in Figure 1 and Figure 2 for a layer system according to Figure 4 and Figure 3, respectively.

In detail, in Figure 1, the width of striated layer system 10 is plotted on the x axis in μm in the range from 0 μm to 80 15 μm . The calculated maximum angle error over all possible angles of an external magnetic field of sensor element 5 is plotted on the y axis in degrees between 0° , i.e., the ideal case, and 5° . Moreover, an external magnetic field having a field strength of 12 kA/m, corresponding to 15 mT, was 20 applied.

First of all, Figure 1 shows a first simulation 20 which would ensue based on layer system 10 according to Figure 3 and Figure 4, respectively. In this context, the external magnetic field has the intensity of 12 kA/m and is rotated completely 25 once by 360° over layer system 10 with respect to the component of the field strength of this outer magnetic field lying in the plane of layer system 10.

Preferably the outer magnetic field is oriented in such a way that it lies as completely as possible in the plane of layer 30 system 10, which is constructed as explained above.

Moreover, in simulation 20, in the absence of the outer magnetic field, the direction of magnetization of reference layer 35 is aligned perpendicularly to the longitudinal direction of striated layer system 10, i.e., the corresponding 5 angle is 90° or 270°. Furthermore, only intrinsic effects which lead to the plotted angle error were taken into account in simulation 20, additional magnetoresistive effects, i.e., primarily a so-called AMR error, having been left out of consideration. This AMR error occurs in ferromagnetic layers 10 and exhibits a \cos^2 -dependency on the direction of the magnetization and the current direction or strip direction. It overlays the GMR effect and, as a rule, has a level of 5% to 30% of the GMR effect.

One recognizes in first simulation 20 that, for a strip width 15 of approximately 7 μm , in the case of the predefined magnetic field, which in practice is predefined in a fixed manner by the existing transducer magnets, given a predefined setting of the angle between the longitudinal direction of striated layer system 10 and the direction of magnetization of reference 20 layer 35 as explained, a minimal angle error occurs which lies nearly at 0°.

Figure 1 further shows a second simulation 21 in which, in addition to simulation 21, the indicated AMR error has also been taken into account. The AMR error does not lead to a 25 relevant change of second simulation 21 compared to first simulation 20.

This being so, in this case as well, given the predefined magnetic field and the predefined orientation of the direction of magnetization of reference layer 35 perpendicularly to the 30 longitudinal direction of the striated layer system, it is best to select a strip width of approximately 7 μm in view of minimizing the maximum angle error.

A third simulation 22, which corresponds to first simulation 20, is also plotted in Figure 1; now, however, the direction of magnetization of reference layer 35 in the case of the given magnetic field has been set to be parallel to the

5 longitudinal direction of the striated layer system, i.e., at an angle of 0° or 180° . Once more, the AMR error was initially disregarded in third simulation 22. If it is taken into account, fourth simulation 23 results, given otherwise identical parameters.

10 It can be inferred from simulations 22, 23 that there is no minimum for the maximum angle error as a function of the strip width.

All in all, it is deducible from Figure 1 that, regardless of the width of the strips of striated layer system 10, it is

15 always more favorable, in the case of the given magnetic field of 12 kA/m, to select the direction of magnetization of reference layer 35 to be perpendicular to the longitudinal direction of the striated layer system, since regardless of the strip width, the maximum angle error is then always

20 smaller than if the angle of 0° to 180° is selected. In particular, it is apparent that the selection of an angle of 90° or 270° between the direction of magnetization of reference layer 35 in the absence of an outer magnetic field and the longitudinal direction of striated layer system 10

25 always leads to a lower maximum angle error than other angles.

Moreover, it is inferable from Figure 1 that, in addition to the matching of this angle to the respective outer magnetic field of defined field strength, there is also an optimal strip width which further minimizes the maximum angle error.

30 This effect is even greater than the effect obtained by the skilled selection of the angle between the direction of

magnetization of the reference layer and the longitudinal direction of striated layer system 10.

Figure 2 shows a situation largely analogous to Figure 1; here, however, the external magnetic field has a field 5 strength of 24 kA/m (corresponding to 30 mT). Here, as well, the maximum angle error is again plotted in degrees as a function of the width of the strips of layer system 10 in μm corresponding to Figure 1.

In this context, understood by the maximum angle error is once 10 more the angle error maximally occurring in response to rotation of the external magnetic field by 360° in the plane of layer system 10, according to the indicated definition.

Plotted in Figure 2 is, first of all, a fifth simulation 24 in connection with a layer system 10 or sensor element 5 15 according to Figure 3 or 4, analogous to Figure 1, the simulation having ensued assuming an external magnetic field of 24 kA/m and an angle between the direction of magnetization of the reference layer in the absence of the outer magnetic field and the longitudinal direction of striated layer system 20 10 of 90° and 270° , respectively. The GMR error, as well as the AMR error, which is produced by shape anisotropy contributions, was taken into consideration in fifth simulation 24. A sixth simulation 25, otherwise corresponding to the fifth simulation, omits this AMR error.

25 When comparing Figure 2 and Figure 1, it is evident that, in contrast to simulations 20, 21, simulations 24, 25 show no minimum of the maximum angle error, which, moreover, considered absolutely, is also even greater.

Also plotted in Figure 2 is an eighth simulation 27 which 30 differs from fifth simulation 24 only in that the direction of magnetization of reference layer 35 has been selected to be

parallel to the longitudinal direction of striated layer system 10, i.e., at an angle of 0° or 180° . In addition to the GMR error, the AMR error has also been taken into account in eighth simulation 27, while a seventh simulation 26, given 5 otherwise identical simulation conditions, in comparison to eighth simulation 27, omits this AMR error.

Here, one can see that, on one hand, in the case of the predefined magnetic field, given an angle between the direction of magnetization of the reference layer in the 10 absence of the outer magnetic field and the longitudinal direction of striated layer system 10 of 0° or 180° , the maximum angle error leads to a perceptibly reduced angle error compared to a corresponding angle of 90° or 270° . In this respect, the situation, given the assumed magnetic field 15 according to Figure 2, is exactly the other way around to that in the case of Figure 1. Moreover, one then observes that the maximum angle error may be further reduced by selecting an optimum strip width which lies at approximately $10 \mu\text{m}$ in the example according to Figure 2.

20 The strategy resulting from the analysis of the simulations according to Figure 1 or 2 is therefore: First of all, the outer magnetic field is predefined from a work interval to which the sensor element is subject during operation. After that, one searches for the angle between the magnetization 25 direction of reference layer 35 in the absence of the outer magnetic field and the longitudinal direction of striated layer system 10 which leads to a minimal maximum angle error. The strip width is also optimized in such a way that a further reduced maximum angle error is obtained, i.e., one searches in 30 particular for the optimum strip width for a minimal maximum angle error.

Finally, it is also inferable from the simulations according to Figures 1 and 2, respectively, that the angle between the direction of magnetization of the reference layer in the absence of the outer magnetic field and the longitudinal direction of the striated layer system is preferably to be selected at 0° and 180° , respectively, or 90° and 270° , respectively. Moreover, the inclusion of the AMR error does not lead to substantial changes of the result in the search for a minimum angle error.

10 In conclusion, it should be stressed again that the provision of conducting layer 11 in the form of short-circuit bars according to Figure 3 leads to an especially substantial reduction of the maximum angle error. It should also be stressed that, in the case of artificial anti-ferromagnet 40,

15 second fixed layer 33 is preferably somewhat thicker than first fixed layer 35, i.e., the reference layer. In addition, the layer construction according to Figure 4 having the indicated materials and layer thicknesses is particularly beneficial with respect to the elucidated minimization of the

20 angle error.